

United States of America

United States Patent and Trademark Office

SCREEN Semiconductor Solutions

Reg. No. 4,839,399

Registered Oct. 27, 2015

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Int. Cl.: 7, 9

Trademark

Principal Register

SCREEN HOLDINGS CO., LTD. (JAPAN CORPORATION)
TENJINKITA-MACHI 1-1, TERANOUCI-AGARU
4-CHOME, HORIKAWA-DORI, KAMIGYO-KU
KYOTO, JAPAN 602-8585

CLASS 7: [printing machines, namely, printing machines for web products, particularly wallpaper, floor coverings and films, parts for the aforementioned machines and lines composed thereof, namely, gravure printing lines, flexo printing lines and combinations of the aforementioned lines; plate making machines, apparatus and their structural parts, for use in the printing industry and for use in printing press applications; bookbinding machines, apparatus and their structural parts, for commercial or industrial use;] semiconductor manufacturing machines, systems and their structural parts [; integrated circuit manufacturing machines, systems and their structural parts; liquid crystal display manufacturing equipment, namely, machines for carrying out the process of coating, cleaning, film formation, or pattern formation to glass substrate or flexible substrate used in liquid crystal display and their structural parts; printed-circuit board manufacturing machines and their structural parts; solar battery manufacturing equipment, namely, machines for carrying out the process of coating, cleaning, film formation, or pattern formation to glass substrate or flexible substrate used in solar battery and their structural parts; lithium ion battery manufacturing equipment, namely, machines for carrying out the process of coating, cleaning, film formation, or pattern formation to glass substrate or flexible substrate used in lithium ion battery and their structural parts; industrial and commercial inkjet printing machines]

CLASS 9: testing machines, namely, surface roughness testing machines and instruments and their structural parts; [testing machines for scratches, color shading, roughness on the surface of the products, testing machines for print defects and missing pages of printed matters;] testing machines for warps of semiconductor wafer or of substrates such as printed circuit boards; testing machines for pattern conditions on the substrates to inspect disconnection, defects, or electrical short circuit in a pattern of a substrate; measuring machines for width, length, and numbers of patterns; [machines for measuring color density of printed matters;] measuring machines for temperature, concentration, and flow rate of process liquid; measuring machines for temperature on the surface of semiconductor wafer and coating thickness on the surface of wafer; optical measuring machines for transmittance and reflectance of thin films; measuring machines for detecting displacement amount on positioning the substrate [; computers; downloadable computer programs for plate making and printing software for producing



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Director of the United States
Patent and Trademark Office



printed matters on computer, process control software for a manufacturing process, image processing software for changing colors, format conversion, and screening of images, testing pattern shape and color density, and for analysis and processing of image data; computer programs recorded on storage media; printing font data that can be downloaded or recorded on storage media; inkjet printing machines, namely, ink jet printers; raster image processors; downloadable image files containing artwork, texts, graphics and photographs; blank digital storage media for use in storage of images and information]

THE MARK CONSISTS OF STANDARD CHARACTERS WITHOUT CLAIM TO ANY PARTICULAR FONT STYLE, SIZE OR COLOR

PRIORITY CLAIMED UNDER SEC. 44(D) ON JAPAN APPLICATION NO. 2014-057927, FILED 07-10-2014, REG. NO. 5767061, DATED 05-29-2015, EXPIRES 05-29-2025

OWNER OF U.S. REG. NO. 4641514, 3990411

No claim is made to the exclusive right to use the following apart from the mark as shown: "SEMICONDUCTOR"

SEC. 2(F) AS TO "SCREEN"

SER. NO. 86-353,993, FILED 07-31-2014

REQUIREMENTS TO MAINTAIN YOUR FEDERAL TRADEMARK REGISTRATION

WARNING: YOUR REGISTRATION WILL BE CANCELLED IF YOU DO NOT FILE THE DOCUMENTS BELOW DURING THE SPECIFIED TIME PERIODS.

Requirements in the First Ten Years*

What and When to File:

- **First Filing Deadline:** You must file a Declaration of Use (or Excusable Nonuse) between the 5th and 6th years after the registration date. See 15 U.S.C. §§1058, 1141k. If the declaration is accepted, the registration will continue in force for the remainder of the ten-year period, calculated from the registration date, unless cancelled by an order of the Commissioner for Trademarks or a federal court.
- **Second Filing Deadline:** You must file a Declaration of Use (or Excusable Nonuse) and an Application for Renewal between the 9th and 10th years after the registration date.* See 15 U.S.C. §1059.

Requirements in Successive Ten-Year Periods*

What and When to File:

- You must file a Declaration of Use (or Excusable Nonuse) and an Application for Renewal between every 9th and 10th-year period, calculated from the registration date.*

Grace Period Filings*

The above documents will be accepted as timely if filed within six months after the deadlines listed above with the payment of an additional fee.

***ATTENTION MADRID PROTOCOL REGISTRANTS:** The holder of an international registration with an extension of protection to the United States under the Madrid Protocol must timely file the Declarations of Use (or Excusable Nonuse) referenced above directly with the United States Patent and Trademark Office (USPTO). The time periods for filing are based on the U.S. registration date (not the international registration date). The deadlines and grace periods for the Declarations of Use (or Excusable Nonuse) are identical to those for nationally issued registrations. See 15 U.S.C. §§1058, 1141k. However, owners of international registrations do not file renewal applications at the USPTO. Instead, the holder must file a renewal of the underlying international registration at the International Bureau of the World Intellectual Property Organization, under Article 7 of the Madrid Protocol, before the expiration of each ten-year term of protection, calculated from the date of the international registration. See 15 U.S.C. §1141j. For more information and renewal forms for the international registration, see <http://www.wipo.int/madrid/en/>.

NOTE: Fees and requirements for maintaining registrations are subject to change. Please check the USPTO website for further information. With the exception of renewal applications for registered extensions of protection, you can file the registration maintenance documents referenced above online at <http://www.uspto.gov>.

NOTE: A courtesy e-mail reminder of USPTO maintenance filing deadlines will be sent to trademark owners/holders who authorize e-mail communication and maintain a current e-mail address with the USPTO. To ensure that e-mail is authorized and your address is current, please use the Trademark Electronic Application System (TEAS) Correspondence Address and Change of Owner Address Forms available at <http://www.uspto.gov>.